

TCAD Avalanche Models

**Group meeting
19-05-2020**

Preview

- **Wolff :**

- First theoretical explanation of charge multiplication.
- Solved quasi-Maxwellian equation with spherically symmetric distribution function.
- Ionization coefficient valid for **high field** strengths :

$$\alpha(\epsilon) = a \exp(-b/\epsilon^2)$$

- **Shockley:**

- A simple statistical model with three adjustable parameters
- Spike distribution function.
- Ionization coefficients valid for **low field** strengths :

$$\alpha(\epsilon) = (q\epsilon/rE_R)\exp(-E_i/qL_R\epsilon)$$

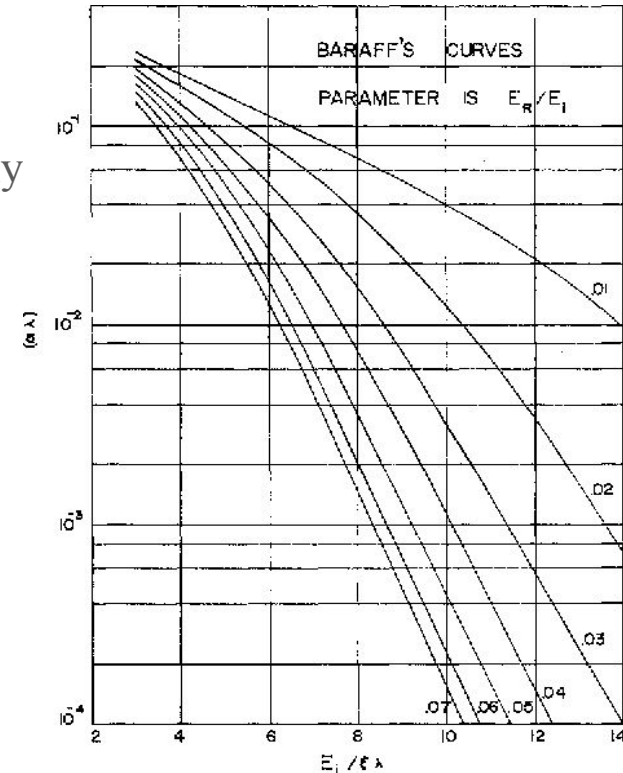
Preview

(Ref. 4)

- **Baraff :**
 - Distribution function corresponds to Wolff's spherically symmetric part and Shockley's spike with constant mean free path.
 - Similarities in slope to Wolff's theory for higher fields and Shockley's theory for lower fields.
- **Crowell & Sze :** modified Baraff's results
 - introduced parameters - average phonon energy lost per scattering and temperature.

$$\langle E_R \rangle = E_R \operatorname{tgh}(E_R/2kT)$$

- Later **Keldysh** confirmed Baraff's results.



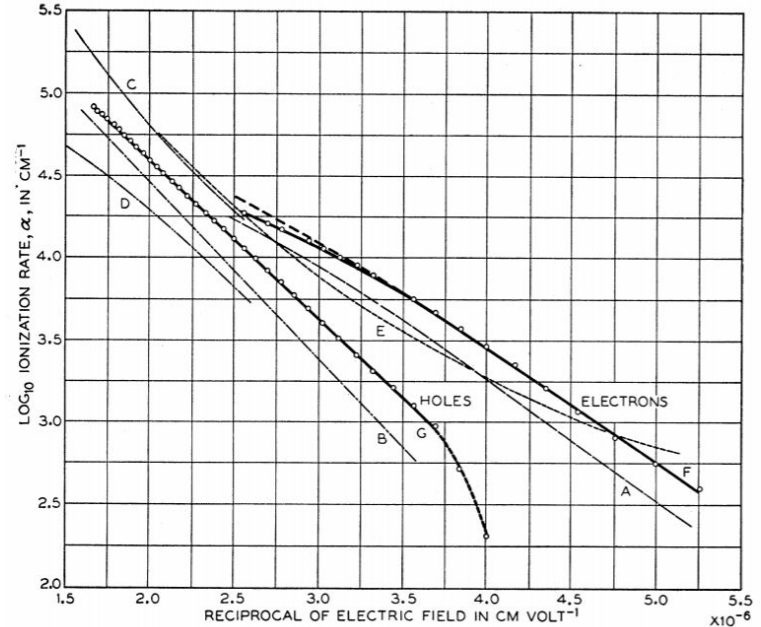
TCAD Avalanche Models

- **Van Overstraeten and de Man Model**
- **Okuto and Crowell Model**
- **Lackner Model**
- **UNIBO (University of Bologna) Model**
- **New UNIBO Model**

Chynoweth Law

(Ref. 7)

- Chynoweth's experimental ionization rates agreed well with measurement of ionization rates in gases : $\alpha = a \exp(-b/\epsilon)$
- Observed linearity in $\ln\alpha$ against E^{-1} graph over wide range of fields.
- Shockley and Van Overstraeten validated this law in the electric field range from $1.75 \times 10^5 - 6 \times 10^5 \text{ Vcm}^{-1}$ (300K).



(A & B correspond to Chynoweth law)

Van Overstraeten Model

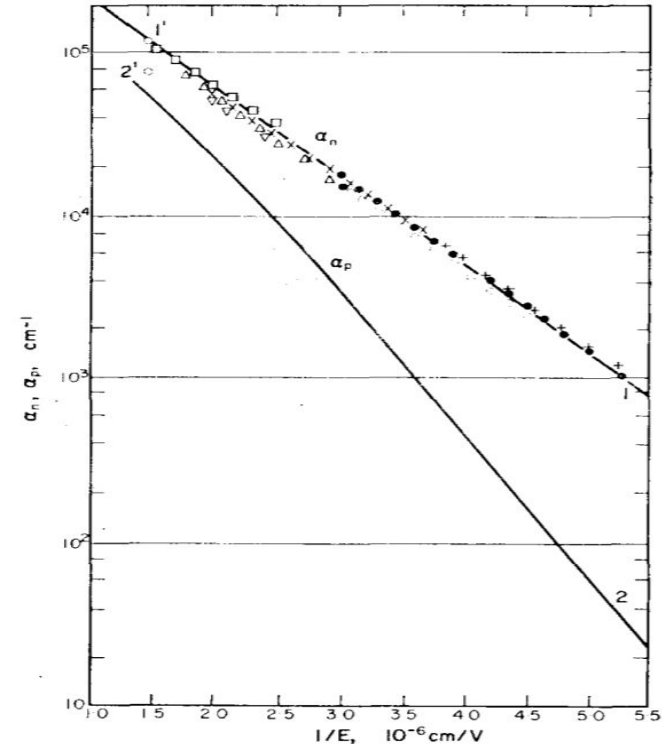
(Ref. 8)

- Used Chynoweth's law for fitting the data and extracting the model parameters :

$$\alpha(\epsilon_{\text{ava}}) = \gamma a \exp(-\gamma b/\epsilon_{\text{ava}}) ;$$

$$\gamma = \frac{\tanh(\hbar\omega_{\text{op}}/2kT_0)}{\tanh(\hbar\omega_{\text{op}}/2kT)}$$

- Valid in the field range of $1.75 \times 10^5 \leq \epsilon \leq 6 \times 10^5 \text{ Vcm}^{-1}$
- Different values of parameters **a** & **b** in low and high range of fields.
- Almost same value of **a** & **b** for 7 different diodes used - made good approximation of Chynoweth's law.



(Symbols represent particular diode)

Van Overstraeten Model

Symbol	Parameter name	Electrons	Holes	Valid range of electric field	Unit
a	a (low)	7.03×10^5	1.582×10^6	$1.75 \times 10^5 \text{ Vcm}^{-1}$ to E_0	cm^{-1}
	a (high)	7.03×10^5	6.71×10^5	E_0 to $6 \times 10^5 \text{ Vcm}^{-1}$	
b	b (low)	1.231×10^6	2.036×10^6	$1.75 \times 10^5 \text{ Vcm}^{-1}$ to E_0	V/cm
	b (high)	1.231×10^6	1.693×10^6	E_0 to $6 \times 10^5 \text{ Vcm}^{-1}$	
E_0	E0	4×10^5	4×10^5		V/cm
$\hbar\omega_{\text{op}}$	hbarOmega	0.063	0.063		eV
λ	lambda	62×10^{-8}	45×10^{-8}		cm
β	beta (low)	0.678925	0.815009	$1.75 \times 10^5 \text{ Vcm}^{-1}$ to E_0	1
	beta (high)	0.678925	0.677706	E_0 to $6 \times 10^5 \text{ Vcm}^{-1}$	

(Ref. 1, pn. 436)

Okuto & Crowell Model

- Empirical model based on Baraff's theoretical model :

$$\alpha(\epsilon_{\text{ava}}) = a [1+c(T-T_0)] \epsilon_{\text{ava}}^\gamma \exp(-(b[1+d(T-T_0)] / \epsilon_{\text{ava}})^\delta) ; T_0=300\text{K}$$

- Energy conservation conditions applied.
- Applicable in the field range of 10^5 - 10^6 Vcm⁻¹ .
- Applied pseudo-local approximation and predicted the existing data with good accuracy.
- “Exact” non-localized approximation considered boundary regions (p-i-n junction).
 - Zero ionization coefficient in boundary dark spaces (p-i & i-n)
 - Constant and close to the values of previous approximation in rest of the region.

Okuto & Crowell Model

Symbol	Parameter name	Electrons	Holes	Unit
a	a	0.426	0.243	V^{-1}
b	b	4.81×10^5	6.53×10^5	V/cm
c	c	3.05×10^{-4}	5.35×10^{-4}	K^{-1}
d	d	6.86×10^{-4}	5.67×10^{-4}	K^{-1}
γ	gamma	1	1	1
δ	delta	2	2	1
λ	lambda	62×10^{-8}	45×10^{-8}	cm
β	beta	0.265283	0.261395	1

(Ref. 1, pn. 437)

Lackner Model

- New theory on pseudo-local ionization probability model for field correction of Chynoweth law :

$$\alpha_v(\epsilon_{ava}) = (\gamma a_v / Z) \exp(-\gamma b_v / \epsilon_{ava}) ; \text{ where } v = n, p$$

$$Z = 1 + (\gamma b_n / \epsilon_{ava}) \exp(-\gamma b_n / \epsilon_{ava}) + \gamma b_p / \epsilon_{ava} \exp(-\gamma b_p / \epsilon_{ava})$$

$$\gamma = \tanh(\hbar\omega_{op} / 2kT_0) / \tanh(\hbar\omega_{op} / 2kT)$$

- Introduced Z parameter in Chynoweth's law.
- Valid in the field range $2 \times 10^5 - 6 \times 10^5 \text{ Vcm}^{-1}$.
- Unlike Van Overstraeten and de Man model, same values of parameters **a** & **b** in low and high field regions.

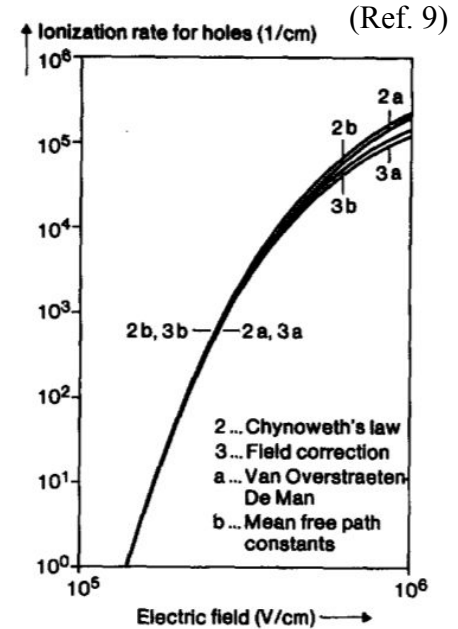
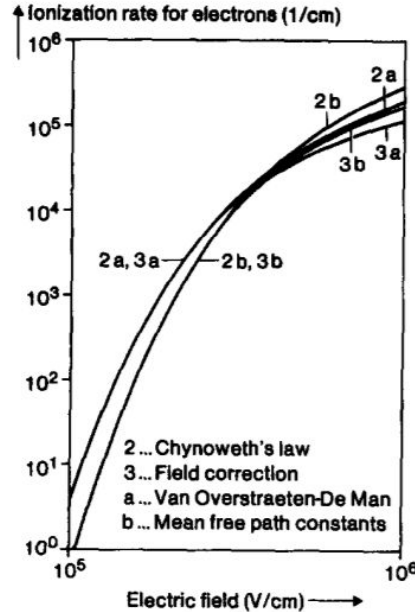
Lackner Model

Symbol	Parameter name	Electrons	Holes	Unit
a	a	1.316×10^6	1.818×10^6	cm^{-1}
b	b	1.474×10^6	2.036×10^6	V/cm
$\hbar\omega_{\text{op}}$	hbarOmega	0.063	0.063	eV
λ	lambda	62×10^{-8}	45×10^{-8}	cm
β	beta	0.812945	0.815009	1

(Ref. 1, pn. 438)

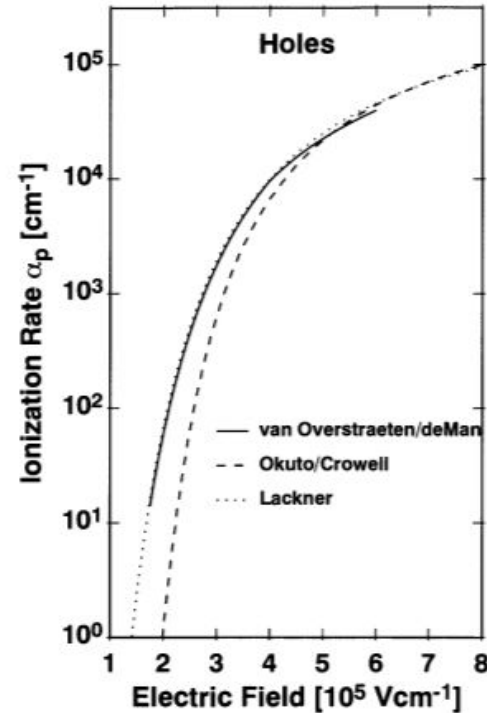
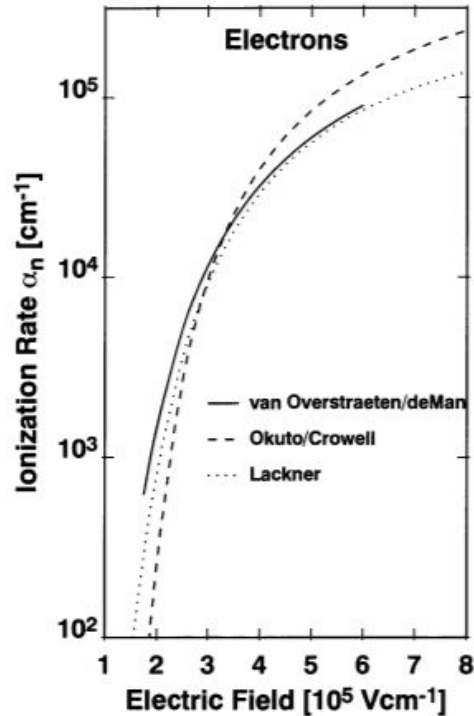
Lackner Model

- Field correction matched well with Chynoweth's law ($Z=1$) for field values $< 4 \times 10^5 \text{ Vcm}^{-1}$.
- Deviation ($Z \neq 1$) in higher range of fields ($> 4 \times 10^5 \text{ Vcm}^{-1}$).
- No validation issue has been provided for field correction approximation.



Comparison of Three Models

(Ref. 6)



UNIBO Model

- Compact model based on impact ionization data generated by Boltzmann solver HARM :

$$\alpha(\epsilon_{\text{ava}}, T) = \epsilon_{\text{ava}} / (a(T) + b(T) \exp[d(T) / \epsilon_{\text{ava}} + c(T)])$$

- Ionization coefficient as a function of field and lattice temperature
- Developed for an extended temperature range (300K-675K) and low electric fields ($4 \times 10^4 - 5 \times 10^5 \text{Vcm}^{-1}$).
- Observed the contribution of non-equilibrium Auger generation at high temperatures - differentiate this model from other standard models.

New UNIBO Model

- Modification of compact UNIBO model by extending the temperature range between 300-773K :

$$\alpha(\epsilon_{\text{ava}}, T) = \epsilon_{\text{ava}} / (a(T) + b(T) \exp[d(T) / \epsilon_{\text{ava}} + c(T)])$$

- Likewise UNIBO, New UNIBO model developed for low electric field range.
- Theoretically based on UNIBO theory
 - Different method of solving the parameters, so, resulted different values.

Conclusions

- Van Overstraeten and Lackner model based on Chynoweth law, but used different parameters
 - reliable for low-field regions (Shockley's low field theory).
- Okuto and Crowell model valid for whole range of fields (Baraff's theory)..
- UNIBO and New UNIBO models showed their reliability for high temperature ranges and low electric fields(down to $4 \times 10^4 \text{Vcm}^{-1}$).
- All models except Okuto & Crowell typically used for self-heating power devices and ESD-protection structures.
- Our focus is on thin p-n junctions with moderate and high field regions - **Okuto and Crowell.**

References

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